

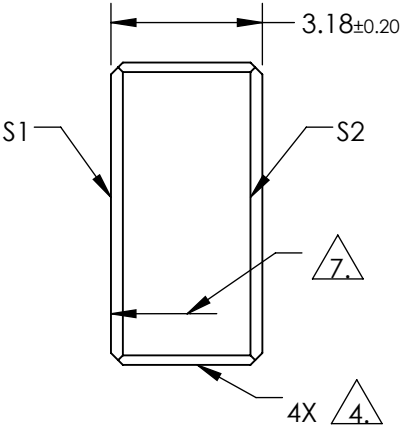
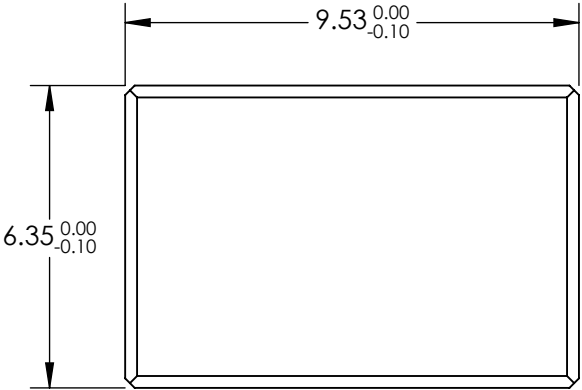
NOTES:

1. SUBSTRATE:  
Fused Silica
2. SURFACE S1 TO BE PARALLEL TO SURFACE S2 TO WITHIN <3 ARCMINS
3. COATING (APPLY ACROSS COATING APERTURE)

S1: R(ABS) >99.8% @ 532nm  
DAMAGE THRESHOLD,  
PULSED: 15 J/cm² @ 1030nm, 20ns, 20Hz

S2: NONE

4. FINE GROUND SURFACE
5. CLEAR APERTURE AND COATING APERTURE ARE CENTERED ON SURFACE
6. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE
7. ARROW ON EDGE WITH LASER ETCH, PENCIL, OR PERMANENT INK POINTS TOWARDS SURFACE S1



**FOR INFORMATION ONLY:  
DO NOT MANUFACTURE  
PARTS TO THIS DRAWING**

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE  
DIMENSIONS ARE FOR REFERENCE ONLY

	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	10-5	COMMERCIAL POLISH
SURFACE FLATNESS	0.10 WAVE	N/A
MIN CLEAR APERTURE	5.40 x 8.10	N/A
MIN COATING APERTURE	5.40 x 8.10	N/A
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION

ALL DIMS IN mm

**Edmund Optics®**

TITLE	6.35 x 9.53mm 532nm 0-45°, Nd:YAG Laser Line Mirror	
DWG NO	39646	SHEET 1 OF 1